PATENT COOPERATION TREATY

PCT/JP2003/013849

PCT

INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY (Chapter II of the Patent Cooperation Treaty)

(PCT Article 36 and Rule 70)

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Applicant's or agent's file reference 144971-077	FOR FURTHER	ACTION	See Form PCT/IPEA/416
International application No. PCT/JP2003/013849		date (day/month/year) 003 (29.10.2003)	Priority date (day/month/year) 30 October 2002 (30.10.2002)
International Patent Classification (IPC) or no H01L 21/205, C23C 16/52	<u> </u>	•	30 October 2002 (30.10.2002)
Applicant	TOKYO ELEC	TRON LIMITED	
This report is the international prelin Authority under Article 35 and trans	ninary examination re mitted to the applican	port, established by this t according to Article 36	International Preliminary Examining 5.
2. This REPORT consists of a total of			heet.
3. This report is also accompanied by A		-	
a (sent to the applicant and	to the International B	ureau) a total of	sheets, as follows:
sheets of the descr and/or sheets conta Administrative Ins	anning recurrications a	drawings which have be uthorized by this Autho	een amended and are the basis of this report rity (see Rule 70.16 and Section 607 of the
sheets which super beyond the disclos	rsede earlier sheets, bure in the internation	out which this Authority al application as filed, a	considers contain an amendment that goes as indicated in item 4 of Box No. I and the
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	licated in the Supple	lining a seguence licting	be and number of electronic carrier(s)) and/or tables related thereto, in computer Sequence Listing (see Section 802 of the
4. This report contains indications relati	ng to the following it	ems:	
Box No. I Basis of the rep	ort		
Box No. II Priority			
Box No. III Non-establishm	ent of opinion with re	egard to novelty, inventi	ve step and industrial applicability
Box No. IV Lack of unity of			
Box No. V Reasoned stater citations and ex	nent under Article 35 planations supporting	(2) with regard to novel	ty, inventive step or industrial applicability;
Box No. VI Certain docume			
Box No. VII Certain defects	in the international ap	plication	
Box No. VIII Certain observa	tions on the internation	onal application	
Date of submission of the demand		Date of completion of	this report
05 April 2004 (05.04.20	04)	01 Sept	tember 2004 (01.09.2004)
Name and mailing address of the IPEA/JP		Authorized officer	
Facsimile No.		Telephone No.	

Translation

INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

International application No.

PCT/JP2003/013849

Box No.	Basis of the report
1. With r	ard to the language, this report is based on the international application in the language in which it was filed, unless e indicated under this item.
	his report is based on translations from the original language into the following language, hich is language of a translation furnished for the purpose of:
	international search (under Rules 12.3 and 23.1(b))
	publication of the international application (under Rule 12.4)
	international preliminary examination (under Rules 55.2 and/or 55.3)
and are	ard to the elements of the international application, this report is based on (replacement sheets which have been to the receiving Office in response to an invitation under Article 14 are referred to in this report as "originally filed" to international application as originally filed/furnished
ti	description:
-	es , as originally filed/furnished
•	received by this Authority on
	received by this Authority on
L tł	claims;
	es, as originally filed/furnished
-	, as amended (together with any statement) under Article 19
-	es* received by this Authority on
	drawings:
pa	, as originally filed/furnished
	received by this Authority on
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a:	quence listing and/or any related table(s) - see Supplemental Box Relating to Sequence Listing.
з. 🔲 ті	amendments have resulted in the cancellation of:
Γ	the description, pages
Ē	the claims, Nos.
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F	the drawings, sheets/figs
F	the sequence listing (specify):
_	any table(s) related to sequence listing (specify):
	report has been established as if (some of) the amendments annexed to this report and listed below had not been established to go beyond the disclosure as filed, as indicated in the Supplemental Box to 70.2(c)). the description, pages the claims, Nos the drawings, sheets/figs the sequence listing (specify): any table(s) related to sequence listing (specify):
If item 4 d	plies, some or all of those sheets may be marked "superseded."
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International application No.

INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

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Box No. V Reasoned statement citations and explan	under Article 35(2) with regardions supporting such states	ard to novelty, inventive step or industrinent	al applicability;
1. Statement			
Novelty (N)	Claims	1-12	YES
	Claims		NO
Inventive step (IS)	Claims		YES
	Claims	1-12	NO
Industrial applicability (IA)	Claims	1-12	YES
	Claims		NO NO

2. Citations and explanations (Rule 70.7)

Claims 1, 3-10 and 12

Document 1: JP, 2001-144019, A (Tokyo Electron Limited)

May 25, 2001 (05.25.01), Paragraphs 0008-0029, Figs. 1-6

Document 1 describes a film-forming device comprising a holding unit holding a plurality of substrates, a reaction container into which the holding unit, a treating gas supply mechanism that supplies a treating gas to the reaction container, and a heating mechanism that performs a film-forming processing on the substrate by heating the reaction container at the time of supplying a treating gas, wherein a flow-rate parameter table that corresponds data of the number of substrates to be treated in one batch with target value data of the flow-rate parameter for a treating gas is measured in advance, control is performed by a flow-rate parameter table that stores such data, a heat treating device having control means for controlling the flow rate of gas based on parameter data, and by temperature table data, and control is performed according to the actual number of embedded wafers.

Document 2: JP, 2000-340554, A (Tokyo Electron Limited)

December 8, 2000 (12.08.00)

Paragraphs 0009-0026, Figs. 1-9 (A)(B)

Document 2 describes technology for controlling film-forming parameters so as to set the same film-forming rate to be roughly the same as that of the standard process.

Controlling by focusing on the film-forming rate as described in document 2 in order to improve reproducibility of the process in the invention described in document 1 would be obvious to a party skilled in the art.

Claims 2 and 11

Claims 2 and 11 set a parameter that is the difference between a minimum value and maximum value when an average film thickness of a thin film to be coated on the substrate by each batch treatment is divided by treatment time at 0.05nm/min. However, determining a value to set for such parameter would be necessarily arrived at by a party skilled in the art. Therefore, claims 2 and 11 could be easily conceived of by a party skilled in the art based on documents 1 and 2.

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main pu	ublished documents (R	tule 70.10)				
Ap	pplication No. Patent No.	Publication of (day/month/ye	late ear)	Filing date (day/month/yea	ır)	Priority date (valid clair (day/month/year)
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